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| Class | Subclass |
| ISSUE CLASSIFICATION | |



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| PATENT NUMBER |
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U.S. UTILITY Patent Application

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| MA | O.I.P.E. MC | PATENT DATE |
| SCANNED | DKI | QA |

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| APPLICATION NO. 09/819520 | CONT/PRIOR | CLASS 385 354 | SUBCLASS 25 24 | ART UNIT 2874 2633 | EXAMINER Sanghavi |
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APPLICANTS
Ansheng Lin
Mario Sanchez

TITLE
Method and apparatus for interleaving and switching an optical beam in a semiconductor substrate

ISSUING CLASSIFICATION

GRANTING

For the purpose of this classification, the following definitions apply:

1. The term "method" includes any process, procedure, or technique for performing a function or operation.

2. The term "apparatus" includes any structure, device, or system for performing a function or operation.

The term "method" includes any process, procedure, or technique for performing a function or operation.

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